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① Difference between N-type and P-type Semiconductors

N-type: this is created by doping silicon with atoms that have extra electrons called donor atoms. This means the N-type semiconductor have extra electrons and the electrons act as the majority charge carriers. It is used when negative charge flow is required. In N-type the electrons carry current.

P-type: this is formed by doping silicon with atoms that lack one electron (acceptor atoms). This creates holes (absence of electrons) that act as positive charge carriers. These missing electrons create holes. P-type contains an excess of holes. Holes are the majority carriers and move to conduct currents.

Both are joined to form a p-n junction, which creates a depletion region that acts as a barrier to current.

② A ~~storage~~ diode operates by applying external voltage across the p-n junction.

Forward Bias occurs when voltage is applied in the same polarity as the P and n materials; the depletion region narrows allowing electrons and holes to cross the junction. Current flows easily and a silicon diode typically conducts above 0.7V. This results in a large current flow (Diode ON)

Reverse Bias: in this case voltage is applied in the opposite polarity to the P-n junction; the depletion region widens blocking charge movement. The result is almost no current flows (except very small leakage) (Diode OFF)

③ An ideal device is a theoretical model that behaves perfectly with no losses or imperfections, for example an ideal diode would conduct perfectly with zero resistance in forward bias and/or block all currents in reverse bias.

(H) Thermal voltage = 25°C

$$\text{formula } V_T = kT/q$$

$$k = 1.38 \times 10^{-23} \text{ J/K}$$

$$q = 1.6 \times 10^{-19} \text{ C}$$

$$T_K = T_C + 273$$

$$= 25 + 273$$

$$= 298 \text{ K}$$

$$V_T = \frac{1.38 \times 10^{-23} \times 298}{1.6 \times 10^{-19}}$$

$$V_T = 0.0257 \text{ V} \approx 26 \text{ mV}$$

$$\textcircled{b} I_S = 40 \text{ nA} = 40 \times 10^{-9}$$

$$n = 2$$

$$V_d = 0.5 \text{ V}$$

$$nV_T = 0.0275 \text{ V}$$

$$I_D = I_S (e^{nV_T} - 1)$$

$$nV_T = 2 \times 0.0275 = 0.0514$$

$$\frac{V_d}{nV_T} = \frac{0.5}{0.0514} = 9.73$$

$$I_D = 40 \times 10^{-9} (e^{9.73} - 1)$$

$$I_D = 40 \times 10^{-9} \times 16800$$

$$I_D = 0.000672A \approx 0.672mA$$